University Of Michigan



COLLEGE OF ENGINEERING THE RADIATION LABORATORY DEPARTMENT OF ELECTRICAL ENGINEERING AND COMPUTER SCIENCE

3228 EECS BUILDING 1301 BEAL AVENUE ANN ARBOR, MICHIGAN 48109-2122 734 764-0500 FAX 734 647-2106 http://www.eecs.umich.edu/RADLAB/

Re: Certification for Omron Receiver

Model: 60000082

FCC ID: OUC60000082 IC: 850K-60000082

POWER OF ATTORNEY

A letter granting Valdis V. Liepa the Power of Attorney is on file and can be provided when so requested.

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REQUEST FOR CONFIDENTIALITY

Pursuant to 47 CRF 0.459, Omron requests that a part of the subject application be held confidential. This comprises Exhibits

- (5) Schematics
- (10) Parts List (Part of Exhibit only)

Omron has spent substantial effort in developing this product and it is one of the first of its kind in industry. Having the subject information easily available to "competition" would negate the advantage they have achieved by developing this product. Not protecting the details of the design will result in financial hardship.

If there are any questions regarding this request, please contact me at the above address or call 734-483-4211, fax 734-647-2106 or e-mail liepa@umich.edu.

Sincerely,
Nald? V. Liga

Valdis V. Liepa Research Scientist University of Michie

University of Michigan

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May 14, 2005

Re: Certification for Omron Receiver

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STATEMENT OF MODIFICATIONS

There were no modifications made to the DUT by this test laboratory. (Also see Section 3.1 of the attached Test Report).

Valdis V. Liepa
Research Scientist